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# Enhanced Light Extraction by Photonic Quasi-Crystals in GaN Blue LEDs

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**Abstract**—The far-field profile of photonic quasi-crystal patterned and unpatterned LEDs, fabricated from commercial epitaxial substrates by electron beam lithography, has been measured prior to lapping and dicing. Emission enhancements reach a maximum of 62%, and are strongly dependent on the filling factor. Qualitative agreement is achieved between 2-D finite-difference time-domain calculations and the experimental data.

**Index Terms**—Electroluminescence, extraction, LEDs, photonic crystals.

## I. INTRODUCTION

THE LAST few years has seen reports of the use of photonic crystals to increase the extraction efficiency of LEDs by coupling the traditionally trapped guided modes in a planar semiconductor structure into radiative modes [1]. Initially, work focused on the theoretical possibilities that photonic crystals can alter the spontaneous emission within an LED via the Purcell effect [2], or used bespoke structures or excitation schemes to demonstrate the principles [3]–[5]. Subsequently, there was a shift toward photonic crystal integration in more commercial LED devices [6].

In order to increase the strength of the interaction between the guided modes and the photonic crystal, the use of a buried photonic crystal has been reported [7], [8]. However, this approach requires a second epitaxial growth process for the regrowth of the capping material. The growth is more challenging, and the intermediate processing step will introduce contamination close to the critical active layers.

The approach taken in this paper is to introduce the periodic structure in the top layer of the high-index GaN waveguide. Since the photonic crystal is separated from the active region, this approach introduces only a small perturbation to the trapped optical modes. Therefore, it is not the photonic bandgap that is being exploited but the coupling of trapped modes with modes that can escape from the material. This simpler process enabled the trends over a relatively wide range of the photonic crystal

design parameters to be studied using readily available commercial epitaxy, but with the drawback that the layer structure may not be the optimum for strong-mode perturbation.

One of the disadvantages of using square or triangular symmetry photonic crystals to improve LED extraction is the azimuthal anisotropy of the light emission that is undesirable in lighting applications [9]. An alternative is to use photonic quasi-crystals (PQCs) that have higher rotational symmetries leading to less azimuthal emission dependency [10]–[12]. These quasi-crystals have long-range order but no short-range translational order.

## II. EXPERIMENTAL DETAILS

Standard unroughened GaN-based LED wafers on sapphire substrates were sourced from commercial suppliers. The surface was patterned with electron-beam lithography (EBL) before the resist pattern (ZEP 520, Zeon Corporation) was transferred via a SiO<sub>2</sub> hard mask to the upper 200-nm-thick p-GaN layer by Cl<sub>2</sub>/Ar plasma etching. The patterned wafer was then processed by conventional lithography into 270 × 270 μm LED chips using 5:5 nm Ni/Au transparent p-contacts.

The PQC patterns were based on square-triangular tiling [10] with three different pitches: 450, 550, and 750 nm. Initially, we aimed for hole diameters of half the pitch, which corresponds to a filling factor or air fraction of ~0.22. In practice, three different beam doses were used in order to achieve three different hole sizes around the design filling factor. Also, each element was written as a square by the EBL system rather than a circle, since this considerably increased the writing speed allowing many more LEDs to be patterned in one run. This enabled a sufficient number of devices to be fabricated for systematic trends to be studied without drift in the EBL system being a factor. Thus, the experimental realizations only approximate to the idealized structures.

Fig. 1 shows a SEM image of one of the photonic crystal chips (PCLED) with a representative area of the quasi-photonic crystal structure defined in its top surface. The depth of the etched holes was measured to be 110 nm by atomic force microscope (AFM). The inset at highest magnification indicates the degree of distortion that occurred to the elements that were written as individual squares.

The SEM observations of the final LEDs reveal that the fabricated patterns differ from that intended in the following different ways: the positional accuracy of the element, its size, and its circularity. Measurements of the geometric parameters of the photonic crystal structures were obtained from SEM images in order to assess the departure from that originally intended [13].

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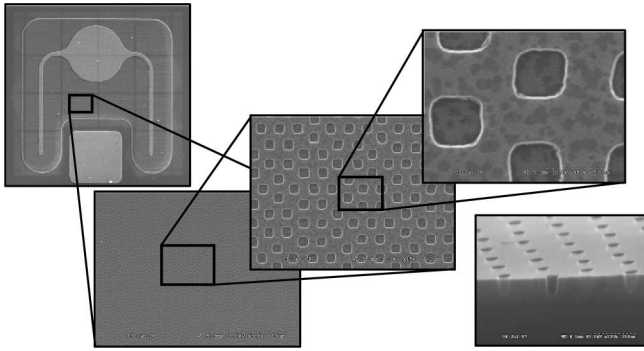


Fig. 1. SEM images of a 750-nm-pitch PCLED along with the cross section from a test sample showing the hole profile.

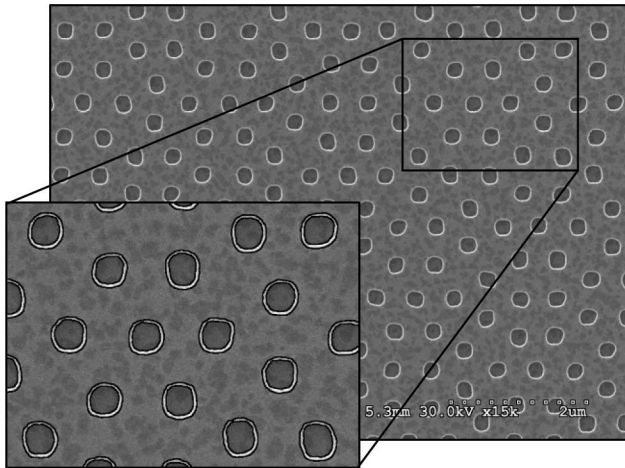


Fig. 2. Example of the SEM image analysis that has been used to determine the fidelity of the photonic crystal. The inset is annotated with the lateral extent of the top and bottoms of the etched holes.

TABLE I  
PCLED PARAMETERS DEDUCED FROM THE SEM AND AFM ANALYSIS THAT DESCRIBE THE PATTERN FIDELITY

	Intended	Actual		
		450 nm	550 nm	750 nm
Air fraction	0.22	0.13	0.13	0.24
		0.17	0.16	0.27
		0.21	0.18	0.30
Positional error	0%	3%	4%	5%
Diameter error	0%	5%	3%	3%
Sidewall angle	90°	77°	77°	77°
Circularity	100%	87%	87%	74%

The SEM images were analyzed to determine the nearest neighbor distances, the distribution of hole sizes, the hole circularity, and, in combination with AFM measurements of the hole depth, the sidewall angle. Fig. 2 shows an example of such an SEM image with the inset additionally annotated with the lateral extent of the top and bottoms of the holes. Table I lists the parameters deduced from the SEM and AFM analysis that describe the pattern fidelity.

For characterization, an optical fiber mounted on a goniometer was used to measure the far-field light distribution of the undiced devices. Control samples with no surface patterning

were interspersed between every patterned LED to minimize the influence on the results of growth and fabrication variations across the wafer fragment. Since the wafer was not diced into chips, these results do not include the effects of emission through the cleaved chip sidewalls. This forms a significant contribution to the total output of diced chips as reported in [14]. Nevertheless, without singulation, comparisons are easier since all that is required for comparing extraction enhancements from differently patterned chips is a simple translation of the wafer by the chip pitch.

### III. RESULTS

Fig. 3 shows the angular electroluminescence from an unpatterned control LED (upper left) and a patterned PQC LED (upper right) as a function of zenith angle and wavelength. The measurements were for TE polarization. Numerous peaks can be observed in the control sample. Those that shift angle with wavelength correspond to Fabry-Perot (FP) fringes that arise from sandwiching the  $\sim 4\text{-}\mu\text{m}$  high-index GaN layer between the lower index sapphire substrate and air. Two further peaks at  $\pm 79^\circ$  that are independent of wavelength correspond to lateral emission from the etched mesa sidewalls.

The FP modes correspond to modes that lie within the normal material extraction cone, and would be subject to Fresnel reflection at the GaN-air interface. This provides limited recycling of photons within the structure, and hence, a very weak interaction with the photonic crystal surface patterning. Nonetheless, for the patterned sample, these broad FP fringes are almost completely broken down, as shown in the lower two graphs of Fig. 3. This provides information about the level of interaction between the relatively shallow photonic crystal and the weakly confined FP modes. These effects have been examined in detail for thin waveguide structures in [15]. Energy previously associated with these weakly confined modes has become redistributed in the far field. In Fig. 3 (lower graphs), we see that the two FP modes closest to the critical angle at  $50^\circ$  and  $65^\circ$  are efficiently smeared out, and only the two remaining FP modes at  $0^\circ$  and  $30^\circ$  survive but are less pronounced. We would expect there to be a relationship between the number of FP modes extracted by the PC and the etch depth of the holes. The data indicate that the photonic crystal, in this case, of depth 110 nm interacts with the higher order FP modes but is not deep enough to interact strongly with the remaining lower order FP modes. An identical behavior is observed for TM-like modes.

The analysis of FP modal behavior provides an insight into the relationships and level of interaction between the photonic crystal and light extracted from the structure but does not tell us anything more about the interaction of the photonic crystal with guided modes that occur as a result of total internal reflection.

Looking more closely at Fig. 3 (top right), inclined lines are observed from the Bragg scattering of the confined optical modes by the photonic crystal. These can be seen more clearly by taking a cross section through the contour plots at 454 nm, as shown in the lower two graphs of Fig. 3. The fine structure can be seen more clearly along with the emission enhancement with the reminder that the jagged line for the PCLED is not

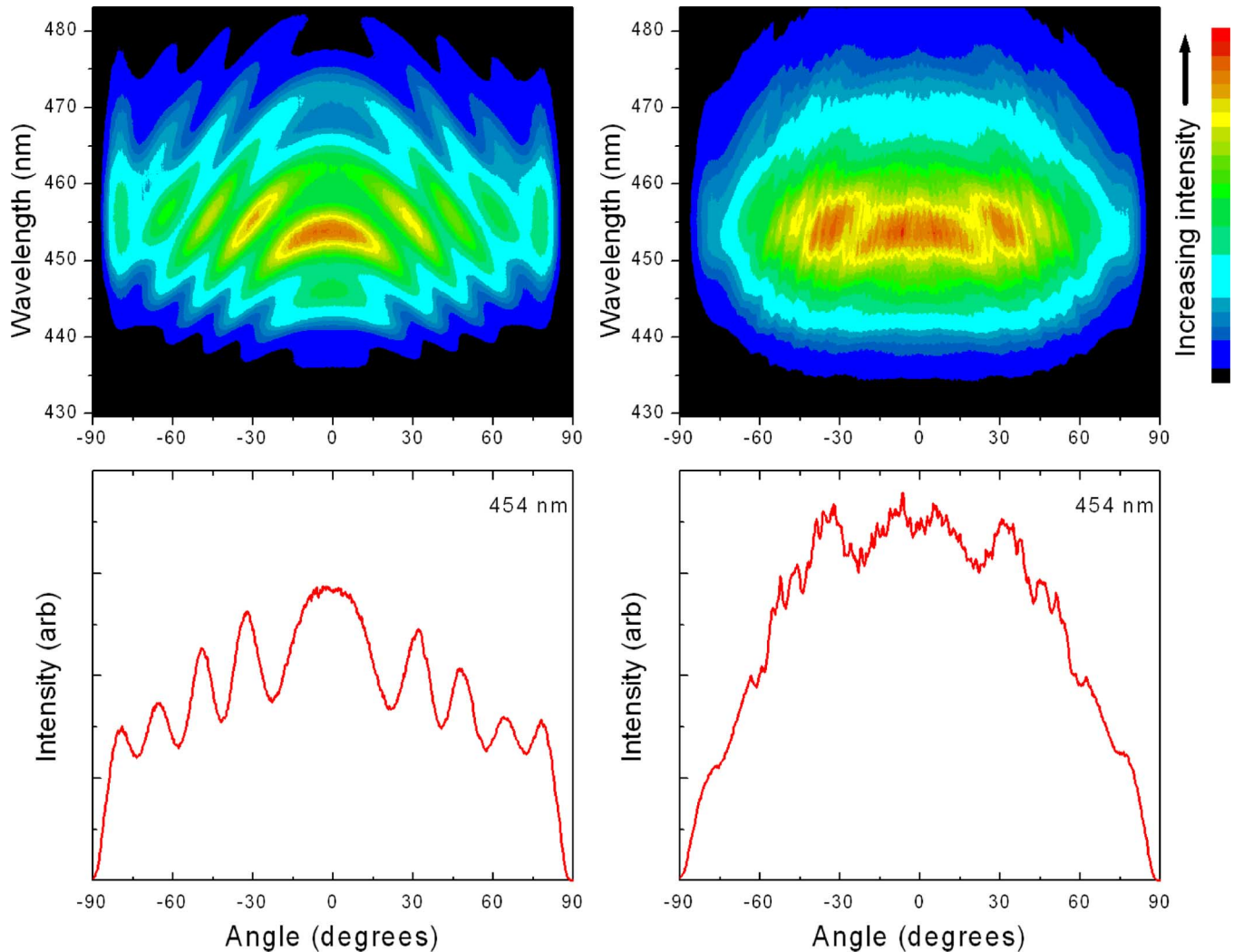


Fig. 3. Angular electroluminescence plots for TE-polarized light for a control LED (left) and a 750-nm-pitch PCLED (right). The intensity versus wavelength is shown in the form of contour plots for the full emission band (above) and as line plots for a single wavelength of 454 nm (below). The centre of the  $x$ -axis corresponds to the surface normal.

caused by noise but rather by the numerous Bragg scattered modes. This fine structure confirms that the photonic crystal does not merely act as a source of inclined surface normals akin to surface roughening. Rather, it has a significant interaction with the trapped guided modes as well. This is further confirmed by the strong reduction in the mesa sidewall emission at  $\pm 79^\circ$  for the photonic crystal sample. As expected, it shows that with the increased light extraction through the top patterned surface, there is a simultaneous reduction of optical energy in the guided modes.

Integrating over the wide  $\sim 40$  nm emission band leads to all the F-P and the Bragg features being smeared out. For the unpatterned control samples, an almost perfect Lambertian far-field profile is recovered, thus confirming the validity of the experimental setup. Within a  $\pm 50^\circ$  cone, this emission was Lambertian to within  $\pm 2\%$ . Outside this range, small peaks representing 5% of the total light output were observed due to emission through the mesa sidewalls.

Between successive measurements, the wafer was translated by the chip pitch in order to allow direct comparison of the

light output intensity of patterned and unpatterned devices. The electrical characteristics of the PCLEDs and the control LEDs were very similar with a forward voltage of 3.2 V at 20 mA drive current.

Fig. 4(a) shows the measured far-field profile of both the control LEDs and the PCLEDs for the three different pitches. The EBL dose was the same ( $150 \mu\text{C}/\text{cm}^2$ ) for the three PQC structures considered, and corresponds to the highest dose used in this paper. The total emission intensity enhancement from the top surface for the best chips for each pitch was estimated by integrating the far-field profile over the extraction cone, whilst assuming that there is no azimuthal dependence on the far-field profile.

In order to confirm this assumption, a second experiment was performed at a fixed zenith angle of  $30^\circ$  for a sample with a 735-nm PQC etched in the surface but without metal contacts or Ni-Au conducting layer. Luminescence that was excited by a He-Cd laser at 325 nm was collected by the same experimental setup as before for azimuthal angles between  $0^\circ$ – $180^\circ$ . The results are shown in Fig. 5. The contour plot shows intensity



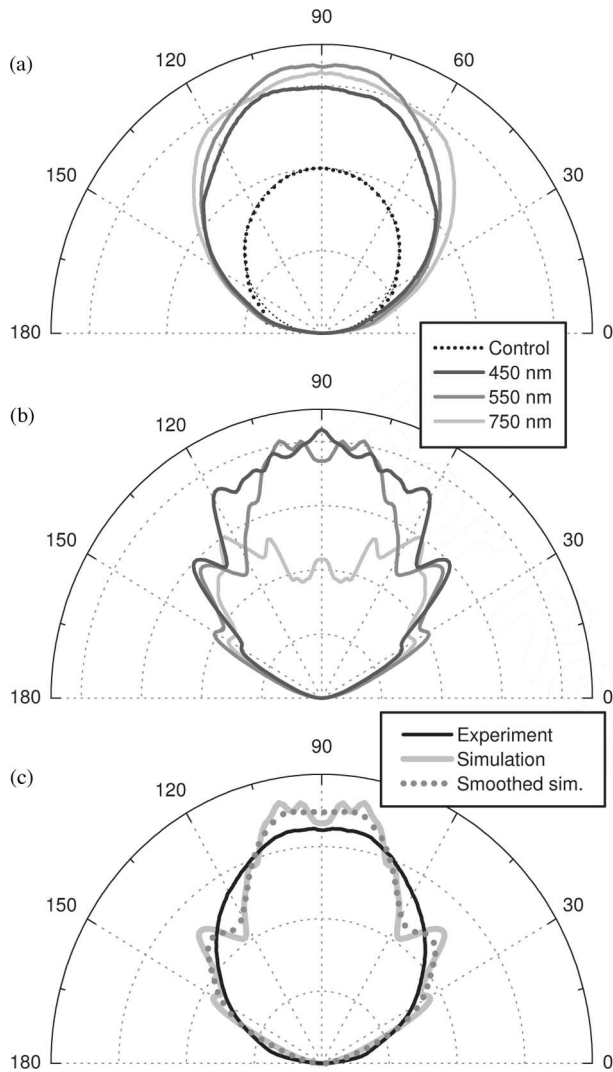


Fig. 4. (a) Measured far-field profile of the PCLEDs and control chip (unpolarized). (b) Simulated far-field profile of the PCLED (not to scale). (c) Qualitative comparison of the measured and simulated far-field profile for the 550 nm PCLED.

modulations that originate from interference between a complex set of criss-crossing Bragg scattered peaks. The line plots (bottom) correspond to horizontal slices in the contour plot at a single wavelength. These clearly reveal the 12-fold symmetry of the quasi-crystal. Further, the intensity modulations are completely smeared out when the emission is integrated over the whole emission band. This is shown by the upper line plots for TE and TM polarization demonstrating there is negligible azimuthal dependence of the far-field profile. These results confirm the advantage of using PQC over a more conventional hexagonal symmetry photonic crystal structure.

Integrating over a  $\pm 90^\circ$  cone, the electroluminescence enhancement ranged between 42%–48% for all three pitches. However, integrating over a full  $\pm 90^\circ$  cone masks a much larger enhancement over cones of smaller angle about the surface normal. The enhancement reached a maximum of 58% for a  $\pm 15^\circ$  cone for the 550-nm-pitch PCLED, and 62% for a  $\pm 45^\circ$  cone for the 750-nm-pitch PCLED.

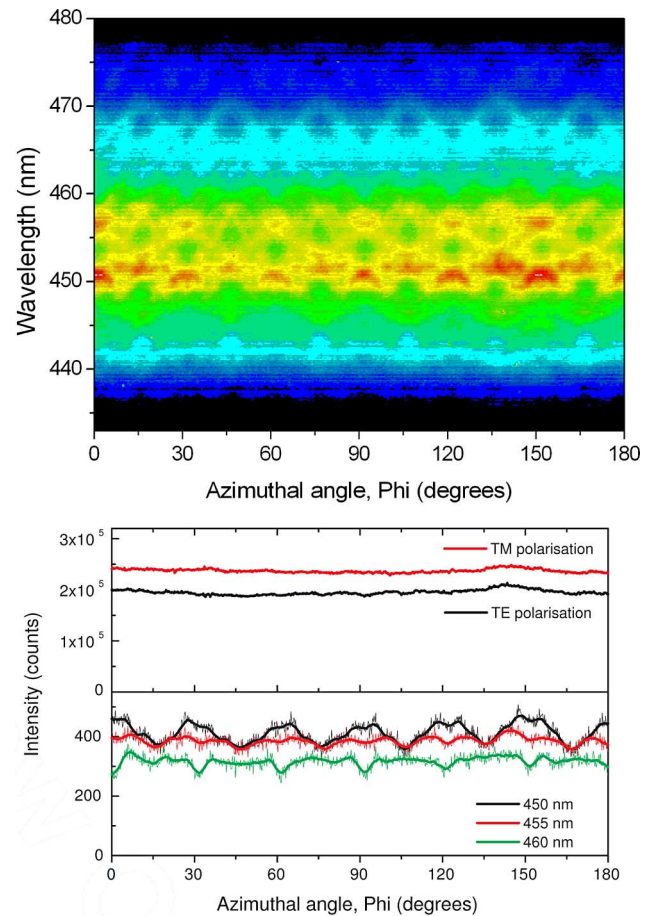


Fig. 5. Photoluminescence from a 730-nm-pitch PCLED for different azimuthal angles. The contour plot shows the intensity for a specific wavelength and azimuthal angle for TE polarized light. The lower line plots show the corresponding intensity at wavelengths of 450, 455, and 460 nm, and highlight the 12-fold symmetry of the PQC. However, once the spectra are integrated over all wavelengths (upper line plot), the 12-fold symmetry is hardly visible.

The dependence on the photonic crystal hole size (i.e., air fraction) is shown in Fig. 6. For each pitch, increasing the hole size caused an increase in the total emission. This is most pronounced for the 550-nm-pitch PCLEDs. Since the hole size has no observable effect on the far-field distribution, the data in Fig. 6 can be summarized by integrating over a  $\pm 90^\circ$  cone, and plotting the result against air fraction, as shown in Fig. 7.

Both the 450 and 550 nm pitches show similar increases in extraction from an air fraction from 0.13 to 0.21. The 750 nm pitch also shows an increase up to 0.30. Whilst the data does not point to a value for an optimum air fraction, it consistently shows that larger holes are better across a broad range of pitches. This result perhaps highlights the complex role of the etched layer in that it acts as both a 2-D photonic crystal laterally as well as an anti-reflection layer in the vertical direction. Further work is continuing to establish the optimum air fraction for the different pitches.

The optical properties of the PCLEDs have also been modeled using a 2-D finite-difference time domain (FDTD) technique with an in-line near- to far-field transform [16]. This allows the conversion of the near-field image of the light coming out of the

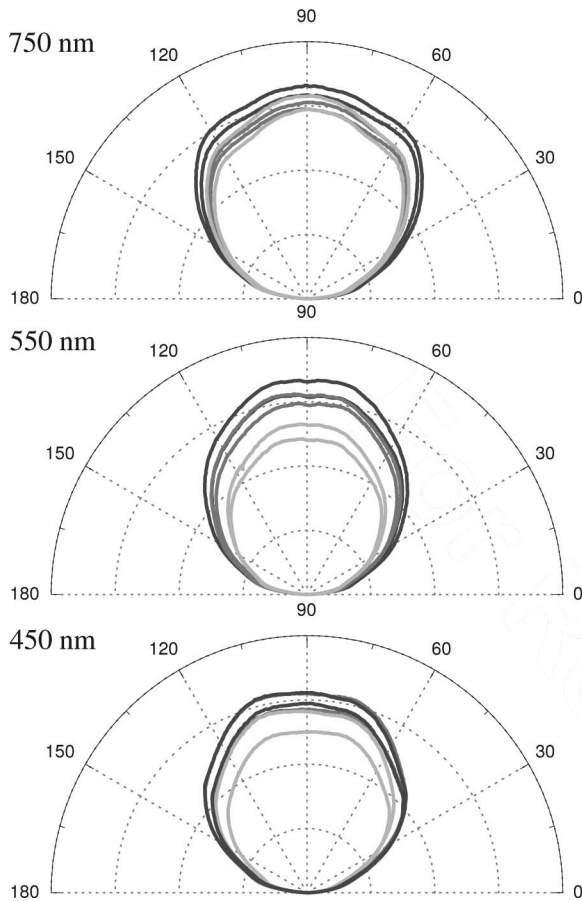


Fig. 6. Measured far-field emission profiles of PCLEDs with pitches of 450, 550, and 750 nm. The light gray, dark gray, and black lines correspond to the PCLEDs written with low, medium, and high electron beam doses.

LED into a far-field emission profile. The LED region is bound by reflecting boundaries in order to simulate a larger structure. A perfectly matched layer boundary condition is used elsewhere. Dipoles oriented to achieve TE-polarized light are placed in the quantum well region. The 2-D algorithm does not allow the full LED to be simulated. Therefore, only a cross section of the device is considered. The output of the simulations is then normalized to a Lambertian emitter in order to obtain far-field profiles.

Calculations of the extraction efficiency and far-field profile were carried out to inform the choice of pattern design. The 450 nm pitch was chosen for high on-axis emission whereas the 750 nm pitch was chosen for low on-axis and high off-axis emissions. Results of these calculations are shown in Fig. 4(b). Qualitatively, the simulations reproduce the key features in the measured enhanced extraction efficiency of the PCLEDs. In general, the maximum enhancement is at emission angles corresponding to the peak angles predicted from the simulations shown in Fig. 4(b).

Fig. 4(c) illustrates this further by comparing the simulated and measured angular dependence of the far-field intensity of the 550-nm-pitch PCLED. Note the simulations were carried out over a smaller spectral bandwidth as that of the measured data. Increasing the spectral range of the simulations will have the

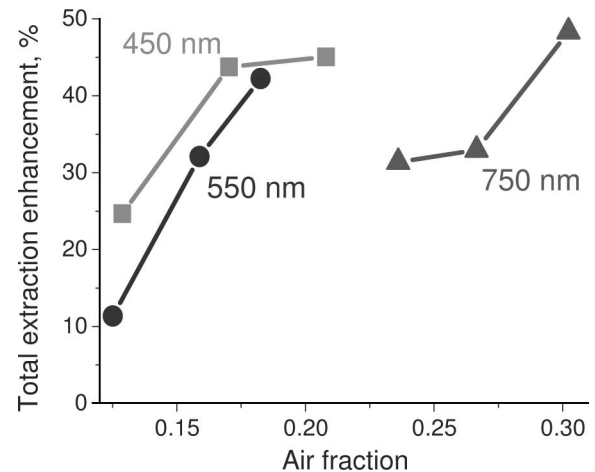


Fig. 7. Total extraction enhancement versus air fraction for the measured PCLEDs. A ratio was taken of the total intensity, integrated over a  $\pm 90^\circ$  cone from the far-field profile, of patterned and unpatterned LEDs.

effect of smoothing the far-field pattern due to its slow variation with wavelength. Averaging the simulated data with respect to angle will have much the same effect. The dotted line in Fig. 4(c) shows the influence of smoothing on the simulated data. The degree of smoothing used here is arbitrary and nonoptimum. The shape of the averaged far-field pattern shows improved qualitative similarity with the experimental data. This demonstrates that the 2-D FDTD simulations are reproducing the key features in the experimental data, and are therefore a useful tool for optimizing photonic-quasi-crystal light-extraction elements.

#### IV. CONCLUSION

In conclusion, results have been presented showing enhanced and more directional light extraction from blue-emitting LEDs with PQC's etched into the device surface. The results confirm a relatively smooth azimuthal dependence of the far-field profile once the broad emission band is taken into account, and point to a strong dependence on the extraction on the photonic crystal air fraction.

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